



RECEIVED

4PR 1 5 1999

**TECHNOLOGY CENTER 2800** 

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Klaus Florian Schuegraf et al.

Title:

SELECTIVE SPACER TO PREVENT METAL OXIDE FORMATION DURING POLYCIDE REOXIDATION

Docket No.:

303.278US1

Filed:

July 30, 1997

Examiner:

O Nadav

Serial No.: 08/902,809

Due Date: April 11, 1999

Group Art Unit: 2811

**Assistant Commissioner for Patents** 

Washington, D.C. 20231

We are transmitting herewith the following attached items (as indicated with an "X"):

X A return postcard.

X Amendment and Response (11 Pages).

- X A Supplemental Information Disclosure Statement (1 pgs.), Form 1449 (1 pgs.), and copies of 2 cited references.
- X A check in the amount of \$240.00 to cover the fee for consideration of Information Disclosure Statement under 97(c).

X Communication Concerning Co-Pending Application (1 pg.).

- X A copy of "Principles of CMOS VLSI Design, A Systems Perspective", by N. Weste, et.al. (4pgs.)
- X A copy of "The Design and Analysis of VLSI Circuits", by L. Glasser, et. al. (12pgs.)

Please consider this a PETITION FOR EXTENSION OF TIME for sufficient number of months to enter these papers and please charge any additional required fees or credit overpayment to Deposit Account No. 19-0743.

SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A.

P.O. Box 2938, Minneapolis, MN 55402 (612-373-6900)

Atty: Robert E. Mates

Reg. No. 35,271

(GENERAL)

B